Sol-gel process: an overview

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Sol-gel process: definition

Sol-gel process is a chemical route used to synthesize glassy or ceramic materials at relatively low temperatures, based on wet chemistry processing, that involves the preparation of a sol, the gelation of the sol and the removal of the liquid existing in fine interconnected channels within the gel.

The growing interest of many researchers in the sol-gel method became apparent only in the mid-1970's, with an increasing amount of published work since that time and, consequently, an increasing number of potentially attractive applications as high technology glasses and ceramics.

The first attempt to synthesize glass from gels was focused on silica, SiO₂.

"Sol-gel processing is a billion-dollar market" (Source: Laser Focus World)

According to a technical market report issued by BCC Research (Wellesley, MA), the U.S. market for sol-gel processing of ceramics and glass is expected to reach \$500 million by 2011 at an average annual growth rate of 8.7%. The global market for sol-gel products in 2006 was \$1 billion; this is forecast to increase to \$1.4 billion by 2011 with an AAGR of 6.3%.

Sol gel is a low-temperature method of fabricating glass in shapes that can range from simple to very intricate. High-quality optical elements are possible, as are doped materials (even containing organic dyes) suitable for laser-gain media. The

U.S. has become the global leader in research and development. <u>However</u>, Japan is able to commercialize sol-gel technology and market products faster.

European competition to the U.S. is mainly from Germany.



Homogenization of the different components in solution (chemical precursors, water, alcohol and catalysts)

Hydrolysis: $M(OR)_n+H_2O\rightarrow M(OH)(OR)_{n-1}+ROH$



Advantages of sol-gel method:

• Versatile: better control of the structure, including porosity and particle size; possibility of incorporating nanoparticles and organic materials into sol-gel-derived oxides;

Extended composition ranges: it allows the fabrication of any oxide composition, but also some non-oxides, as well as the production of new hybrid organic-inorganic materials, which do not exist naturally;

Better homogeneity: due to mixing at the molecular level; high purity;

Less energy consumption: there is no need to reach the melting temperature, since the network structure can be achieved at relatively low temperatures near T_a;

- Coatings and thin films, monoliths, composites, porous membranes, powders and fibers;
- No need for special or expensive equipment.

Drawbacks of sol-gel method:

- Cost of precursors;
- Shrinkage of a wet gel upon drying, which often leads to fracture due to the generation of large capillary stresses and, consequently, makes difficult the attainment of large monolithic pieces;
- Preferential precipitation of a particular oxide during sol formation (in multicomponent glasses) due to the different reactivity of the alkoxide precursors;
- Difficult to avoid residual porosity and OH groups.

Metal alkoxides

Table. Representative metal alkoxides employed in glass preparation by sol-gel processing. Adapted from M. Yamane and Y. Asahara. Glasses for Photonics (Cambridge University Press, Cambridge 2000).

	A 11	F arman (a	Boiling Point (°C/mmHg)		
	Alkoxide	Formula			
-	Silicon ethoxide (TEOS)	Si(OEt)4	168/760		
	Silicon methoxide (TMOS)	Si(OMe)4	153/760		
	Boron n-butoxide	B(OBu ⁿ)₃	128/760		
	Aluminium n-propoxide	Al(OPr ⁿ)₃	205/1.0, 284/10.0		
	Aluminium n-butoxide	Al(OBu ⁿ)₃	242/0.7, 284/10.0		
	Aluminium tert-butoxide	Al(OBu ^t)₃	151/1.3, 185/10.0		
	Germanium ethoxide	Ge(OEt)4	86/12.0		
	Titanium ethoxide	Ti(OEt)4	103/0.1		
	Titanium tert-butoxide	Ti(OBu ^t) ₄	93.8/5.0		
	Zirconium ethoxide	Zr(OEt)4	190/0.1		

✓ silicon alkoxides are not very reactive : hydrolysis-condensation reaction rates must be increased by catalysts

✓ hydrolysis and condensation reactions of non-silicate metal alkoxides must be controlled by using chemical additives (complexing ligands, e.g. acetylacetone)

H (hydride) (methyl) CH₃-(Si) – OCH₂ (methoxy) CH₂CH₂CH₂-NH₂ (aminopropyl

very reactive: it reacts with water to yield silanol (-Si-OH) species and, additionally, will add across carbon-carbon double bonds to form new carbon-silicon-based materials.

very reactive and hydrolysable methoxysilyl structure.

Organosilane: at least one carbon-silicon bond (very stable, very nonpolar and gives rise to low surface energy, non-polar, hydrophobic effects)

Characteristics of Various Organic Substituents on Silanes

Organosilanes R-Si(OMe) ₃							
R	Characteristics of "R"						
Me	Hydrophobic, Organophilic						
Ph	Hydrophobic, Organophilic, Thermal Stability						
i-Bu	Hydrophobic, Organophilic						
Octyl	Hydrophobic, Organophilic						
-NH(CH ₂) ₃ NH ₂	Hydrophilic, Organoreactive						
Ероху	Hydrophilic, Organoreactive						
Methacryl	Hydrophobic, Organoreactive						

Acid and base-catalysis

acid catalyzed conditions ("polymeric" gel) **base catalyzed conditions** ("particulate" gel) SOL branched Far from gel point clusters - 100 Å -SOL Near gel point hydrolysis reaction is speeded up more efficiently than the condensation reaction growth and entangled primarily additional branching linear macromolecules polymer chains are weakly cross-linked and the structure can be highly compacted before gelation GEL POINT linked clusters aditional crosslinks at junctions

SOL Far from gel point

SOL Near gel point

GEL POINT

residual spaces in between the clusters

Coating methods



(The faster the substrate is withdrawn, the thicker the deposited film)





Industrial dip-coating system



Stages of the spin-coating process: (I) deposition, (II) spin-up, (III) spin-off and (IV) evaporation. (not to scale).

Thickness of the films depends on:

rheological properties of the solutions; the spinning conditions, such as spinning time, velocity and atmosphere, and the heat treatment time and temperature.

Other tecnhiques for thin film deposition onto substrates:

spray-coating

the surfaces are sprayed with fine disperse solutions. Used mostly for protective coatings.

roll-coating



Applications

Thin films (multilayers) for optical planar waveguides (optical amplifiers)

Ana C. Marques et al., Glass Technology, 46, 2 (2005) 50; Rui M. Almeida et al., J. Sol-Gel Sci. Technol., 31 (2004) 317



Light propagation in a planar waveguide of composition SiO_2 -Ti O_2 -Al₂O₃ (silica-on-silicon substrate; prism coupling).

Optical propagation loss ~ 0.2 dB/cm.

Multilayers for reaching desired thickness



Laser beam used for photoluminescence measurements (M-mirror, CL-convergent lens, L-laser source, C-chopper, SH-sample holder) **Photonic crystals (1-D):** alternate layers of SiO₂ and TiO₂ with one or more defect layers

Rui M. Almeida, Ana C. Marques, J. Non-Cryst. Sol. 352 (2006) 475–482



Wavelength (nm)

Super-hydrophobic thin films by sol-gel and phase separation

H. Hou et al., J. Sol-Gel Sci. Technol. (2007) 43:53-57



Thin films prepared with 0.075 g PAA. The contact angle for water was 151°.

The phase separation, induced by the addition of poly(acrylic acid) (PAA), originates the hill-like surface morphology: similar to the papillae surface morphology from natural surface of the lotus.

Surface roughness of films and contact angles of water droplets increase with increasing PAA concentration (up to 0.075 g).



Commercial applications of the sol-gel process in Japan

Muromachi et al., J Sol-Gel Sci Techn (2006) 40:267-272

Hydrophobic coatings

Hydrophobicity is provided by fluoroalkyl groups arranged in good order on film surface (contact angle for water: 100-108°)

Glass

Hydrophobic layer

SiO₂ under-layer (to obtain higher environmental stability and abrasion resistance)

• UV absorbing coatings

SiO2-TiO2-CeO2 (Mole ratio: Si : Ti : Ce = 5 : 10 : 7, $d^* = 130$ nm) SiO2-ZrO2 (Mole ratio: Si : Zr = 3 : 4, d = 77nm) Glass

(1)*: 'd' represents physical thickness.

Colored coatings

The development of colored coatings with high visible transmission has been achieved e.g. using Au fine particles dispersed in the silica matrix.

• IR absorbing coatings, low reflective coatings, etc...

Advantages in terms of industrial process: feasibility of coating a large area; only small investment is required.



Alkoxide-derived nanometer-sized silica

Yamane et al., J Sol-Gel Sci Techn (2006) 40:273–279

Silica nanoparticles used in the final polishing of silicon wafers for the fabrication of integrated circuits.

The particles are cocoon-like in shape and have almost replaced conventional abrasives because of the advantages over spherical particles of similar size in terms of obtaining high polishing efficiency for good surface finish.

• Treatment of paper with methyltrimethoxysilane

Yamane et al., J Sol-Gel Sci Techn (2006) 40:273-279

treatment of paper with an alkoxide solution for water repellent and oil resistance properties, which leads to new products for disposable tableware or cooking ware for microwave oven use.

		I V				
			Water	Anti-oozing	Thermal	
	Material	Strengthening	repellency	of oil	durability	Remark
	Methyltrimethoxysilane	0	0	0	0	
	Silicone	×	0	×	Δ	Good stripping quality
Comparison of various	Acryl or Epoxy resin	\triangle	\triangle	0	×	1 2
nprovement of the properties f paper Florin-containing polymer	Florin-containing polymer	×	0	0	×	Releasing toxic compounds

Antireflective coatings

The sol-gel dip coating process has also been used to **deposit thin films on large size plastic panels**. By developing sols with different refractive indices, multi-layer thin-film **antireflective coating** stacks were designed and fabricated. These coatings possess good uniformity and meet stringent automotive specifications. This technology has been commercialized successfully for **dashboard instrument panel** application in Toyota's new hybrid engine car, named Prius.

Inorganic and hybrid coatings for chemical protection of steels

Ana C. Marques, Janet Gallardo, Alicia Durán, Boletín de la Sociedad Española de Cerámica y Vidrio, 40, 6 (2001) 429.

Corrosion resistance of stainless steel can be enhanced through the application of SiO_2 coatings. However, these coatings are sensitive to alkaline attack, that produces the partial dissolution of the SiO_2 network...

Composition: SiO₂-TiO₂ and SiO₂-ZrO₂ (precursors: MTES and TBOZr or TBOTi) dip-coating

The electrochemical resistance and coating stability were evaluated from cyclic polarization tests in aqueous NaCI, at room T, performed on coated AISI304 stainless steel.

Comparing the performance of stainless steel coated with 50%SiO₂-50%ZrO₂ to uncoated stainless steel:

- Decrease of current density by one order of magnitude

- Larger difference between pitting potential (Ep) and repassivation potential (Er)

The coatings revealed a high resistance against alkaline media preserving an excellent electrochemical behavior in Cl⁻ rich solutions.





Bulk, dense glasses containing nanoparticles

Ana C. Marques and Rui M. Almeida, J. Non-Cryst. Solids (2007, in press)



Bulk materials with hierarchical porosity at multiscale, using phase separation

Ana C. Marques, Himanshu Jain, Rui M. Almeida, Eur. J. Glass Sci. Tech. (in press) 2007.



Scanning electron micrographs of glass samples of composition 70% $SiO_2 - 30\%$ CaO (mol%), prepared by the normal (left) and modified (right) sol-gel technique

✓ bone scaffolds (Biomaterials)

- ✓ drug delivery
- ✓ catalysis
- ✓ hydrophobicity
- ✓ chromatography
- ✓ high-temperature applications

Conclusion

Sol-gel chemistry is still in its infancy and a better understanding of the basic inorganic polymerization chemistry is necessary in order to explore all the functionalities and possible applications of the process.

Sol-gel process is very attractive from the view point of small investment and new functions, although disadvantages such as sensitivity to process conditions should be considered.

versatility and purity...